Present: Christian Ganne, LeeCC; Robert Hochstein, LeeCC, Sharon Sussman, KapCC; Meidor Hu, HawCC, Debbie Nakama, UHMaui; Suzette Robinson, UHCC office

ACM 255, Cinema and Digital Media:
Courses with similar components include:

<table>
<thead>
<tr>
<th>Campus</th>
<th>Course Alpha and No.</th>
<th>Course Title</th>
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<tbody>
<tr>
<td>LeeCC</td>
<td>DMED 150</td>
<td>Film Analysis and Storytelling</td>
</tr>
<tr>
<td>LeeCC</td>
<td>TVPRO 101</td>
<td>Film and Video Production Process and Business Operations</td>
</tr>
<tr>
<td>HawCC</td>
<td>Art 209</td>
<td>Image in Motion Studio</td>
</tr>
<tr>
<td>KapCC</td>
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Campus Reports:
HawCC is preparing the program proposal for an A.S. in Digital Media with two specializations—Digital Video and Graphic Design. Two of the courses in the program will align with the ACM program.

UHMaui does not have a digital media program but the Maui high schools have strong digital media (computer-based, not film) and animation type programs.

LeeCC’s TVPRO program averages 20 majors per year, and over the last 23 years has had a work placement of over 83%. The program is switching to high definition with plans for all of its equipment to be high def by fall 2011.

LeeCC’s digital media program is planning a 3rd year program called Advanced Digital Cinematography. Changes were also made to the Digital Media/Arts/Specialization chart based on new information from LeeCC.

Action: Christian will send Suzette information on LeeCC’s A.S. program

KapCC is preparing a 3rd year program called Advanced Animation Certificate.

Dual Credit Articulated Program of Study:
Horizontal articulation among the community colleges of Art 112 had been started, led by Violet Murakami and Arled Garcia. Suzette will research its status. Update: Suzette found the UH System Articulation Agreement for Digital Media Arts (HawCC, LeeCC, KapCC) for Art 112. See attached.
Committee Membership:
Additional members will be included to the committee. See attachment.

Next meeting: Fall 2011